

IntlVac - Nanochrome I Sputterer



- Precision optical coatings of metals and dielectrics – Si, SiO₂, Si₃N₄
SiOxyNitride
- High vacuum capabilities: able to achieve ultimate pressures of approximately 5×10^{-8} Torr
- Ability to fit up to three 4" sputtering cathodes with indirect cooling
- R.F., A.C. and D.C. Planar Magnetron Sputtering Applications
- Automated system control with a touch-screen interface